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	Application No.	Applicant(s)	
Notice of Allowability	09/754,273	CHOI ET AL.	
	Examiner	Art Unit	
	Elizabeth Keaney	2882	
The MAILING DATE of this communication app All claims being allowable, PROSECUTION ON THE MERITS IS herewith (or previously mailed), a Notice of Allowance (PTOL-85 NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT R of the Office or upon petition by the applicant. See 37 CFR 1.31	ears on the cover sheet with 5 (OR REMAINS) CLOSED in ) or other appropriate commu RIGHTS. This application is si	this application. If not include nication will be mailed in due	ded e course. <b>THIS</b>
1. This communication is responsive to the amendment and	request for continued examin	ation filled 5 April 2004.	
2. The allowed claim(s) is/are <u>1-15</u> .			
3. The drawings filed on <u>07 August 2003</u> are accepted by the	e Examiner.		
4. ☐ Acknowledgment is made of a claim for foreign priority u a) ☐ All b) ☐ Some* c) ☐ None of the:		r (f).	
1. Certified copies of the priority documents hav			
2. Certified copies of the priority documents hav	• •	<del></del>	
3. Copies of the certified copies of the priority do	ocuments have been received	in this national stage applic	ation from the
International Bureau (PCT Rule 17.2(a)).  * Certified copies not received:			
Applicant has THREE MONTHS FROM THE "MAILING DATE" noted below. Failure to timely comply will result in ABANDON'THIS THREE-MONTH PERIOD IS NOT EXTENDABLE.	of this communication to file MENT of this application.	a reply complying with the re	equirements
5. A SUBSTITUTE OATH OR DECLARATION must be subminFORMAL PATENT APPLICATION (PTO-152) which give	nitted. Note the attached EXA res reason(s) why the oath or	MINER'S AMENDMENT or declaration is deficient.	NOTICE OF
6. CORRECTED DRAWINGS (as "replacement sheets") mu	st be submitted.		
(a)  including changes required by the Notice of Draftsper	son's Patent Drawing Review	( PTO-948) attached	
1) 🗌 hereto or 2) 🔲 to Paper No./Mail Date	<u></u> .		
(b) ☐ including changes required by the attached Examiner Paper No./Mail Date	's Amendment / Comment or	in the Office action of	
Identifying indicia such as the application number (see 37 CFR each sheet. Replacement sheet(s) should be labeled as such in	1.84(c)) should be written on th the header according to 37 CFF	e drawings in the front (not th	e back) of
7. DEPOSIT OF and/or INFORMATION about the deposit attached Examiner's comment regarding REQUIREMENT	osit of BIOLOGICAL MATE	RIAL must be submitted.	Note the
Attachment(s)	• <b>-</b>	10	
<ol> <li>Notice of References Cited (PTO-892)</li> <li>Dotice of Draftperson's Patent Drawing Review (PTO-948)</li> </ol>		ormal Patent Application (PT	·U-152)
	Paper No./M	mmary (PTO-413), ⁄/ail Date	
<ol> <li>Information Disclosure Statements (PTO-1449 or PTO/SB/I Paper No./Mail Date</li> </ol>	08), 7. ☐ Examiner's A	Amendment/Comment	
4. Examiner's Comment Regarding Requirement for Deposit	8. 🛛 Examiner's S	Statement of Reasons for All	owance

of Biological Material

9. Other \_\_\_\_.

## **DETAILED ACTION**

Receipt is acknowledged of the Amendment filled 5 February 2004 and the Request for Continued Examination filled 5 April 2004.

Claims 1,2 and 14 are directed to an allowable product. Pursuant to the procedures set forth in the Official Gazette notice dated March 26, 1996 (1184 O.G. 86), claims 2-13, directed to the process of making or using the patentable product, previously withdrawn from consideration as a result of a restriction requirement, are now subject to being rejoined. Claims 2-13 are hereby rejoined and fully examined for patentability under 37 CFR 1.104.

Since all claims previously withdrawn from consideration under 37 CFR 1.142 have been rejoined, the restriction requirement made in the Office action mailed on 12 March 2003 is hereby withdrawn.

## Allowable Subject Matter

Claims 1-15 are allowed over the prior art.

The following is an examiner's statement of reasons for allowance:

Re claims 1,2,14 and 15: The best prior art of record discloses a field emission device comprising a substrate, a cathode, micro-tips having nano-sized surface features, a gate insulation layer and a gate electrode. However, the prior art fails to teach or fairly suggest a field emission device comprising a substrate, a cathode, micro-

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tips having nano-sized surface features, a gate insulation layer and a gate electrode, wherein the mircor-tips and non-sized surface features are of a homogeneous material as claimed in claims 1 and 14. Claims 2 and 15 are allowable by virtue of their dependency.

Re claims 3-13: The best prior art of record discloses a method for fabricating a field emission device comprising forming a cathode, a gate insulation layer, a gate electrode and micro-tips having nano-sized surface features. However, the prior art fails to teach or fairly suggest a method for fabricating a field emission device comprising forming a cathode, a gate insulation layer, a gate electrode and micro-tips having nano-sized surface features, forming a carbonaceous polymer layer, etching the carbonaceous polymer layer so as to form nano-sized surface features on the micro-tip wherein the micro-tip and the nano-sized features are of a homogenous material as claimed in claims 3 and 12. Claims 4-11 and 13 are allowable by virtue of their dependency.

Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

## Conclusion

The prior art made of record and not relied upon is considered pertinent to applicant's disclosure.

• US Patent 6,632,114 discloses the current state of the art.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Elizabeth Keaney whose telephone number is (571)272-2489. The examiner can normally be reached on Monday-Thursday 5:30-4.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Ed Glick can be reached on (571)272-2490. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

DAVID V. BRUCE
PRIMARY EXAMINER

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